Ref. No. EX/PRN/T/226/2019

BACHELOR OF PRINTING ENGINEERING EXAMINATION 2019 (Second Year, Second Semester) PRINTING SURFACE PREPARATION

Time: Three hours

Full Marks: 100

Answer any five questions

- 1. a) Why is Al selected as base metal for image surface preparation of Offset Process?
 - b) Discuss in brief the chemical graining and electrochemical graining.
 - c) Discuss in brief the brush graining along with merits and demerits.
 - d) What is Stop-out in deep etch plate making?

5+(3+3)+(3+3)+3=20

- 2. What are the factors which influence the sensitivity to light of the bichromated colloid films? Discuss in brief.
- 3. a) What are the purposes of graining?
 - b) What are the purposes of counter etching?
 - c) What are the factors which influence the mechanical graining? Discuss. 5+5+10=20
- 4. a) Why should the pH of the gum arabic solution used in desensitizing purpose of the Offset plate be kept near about 3.0 for most effective result?
- b) What are the properties gum arabic possess for which it is considered as desensitizing solution for lithoplate?
 - c) What are the preferences of the plate-makers and printers so far as grain is concerned?
 - d) What are the merits and demerits of waterless offset process?

5+6+4+5=20

- 5. a) What are the properties Silicone resin have for which it is used as imaging material for the non-image areas of the Waterless Offset Plate?
 - b) What do you mean by Additive and Subtractive Pre-sensitized plate? Discuss.
 - c) Discuss in brief, how plate grains are evaluated.
- d) What happens when One Step additive developing solution is rubbed on exposed diazo plate?
 - e) What are the functions of the transparent protective layer in Waterless Offset Plate?

4+4+7+3+2=20

- 6. a) What are the advantages of the gum deep etch plate over the PVA deep etch plate?
 - b) What are the advantages of the deep etch plates over the surface plates?
- c) What is the composition of the brunaking solution used in Egg Albumen and Deep etch processes? Discuss its effect on coating thickness of bichromated colloid surface and deepetch plates?
 - d) Why is alkaline developer used in positive working Presensitized plate?

3+7+(3+4)+3=20

7. a) Discuss in brief, the basic structure of the negative working waterless offset plate.

b) Discuss in brief, the imaging and developing of the negative working waterless offset plate.

5+15=20